

Module Description, available in: EN

Applied micro & nano technologies

General Information

Number of ECTS Credits

3

Module code

TSM_AppMNT

Valid for academic year

2021-22

Last modification

2021-02-12

Coordinator of the module

Martin Gutsche (OST, martin.gutsche@ost.ch)

Explanations regarding the language definitions for each location:

- Instruction is given in the language defined below for each location/each time the module is held.
- Documentation is available in the languages defined below. Where documents are in several languages, the percentage distribution is shown (100% = all the documentation).
- The examination is available 100% in the languages shown for each location/each time it is held.

	Lausanne			Lugano	Zurich		
Instruction					X E 100%		
Documentation					X E 100%		
Examination					X E 100%		

Module Category

TSM Technical scientific module

Lessons

2 lecture periods and 1 tutorial period per week

Entry level competences

Prerequisites, previous knowledge

Basic knowledge in chemistry and physics

Brief course description of module objectives and content

Based on selected examples this modul imparts the scientific and technological basics as well as the possibilities and the perspectives of the microand nanotechnologies. The students should become sensitive to the enormous potential of applications of this field and acquire a certain ability in handling it.

Aims, content, methods

Learning objectives and competencies to be acquired

- · the students know the the scientific and technological basics of this technology
- the students have a general unterstanding of the numerous fields of the micro- and nanotechnologies and their applications
- the students are able to combine the advantages of scaling and materials with the desired functions of the device.
- based on selected nanodevices the students develop the ability to apply specific nano properties

Module content with weighting of different components

- Introduction in the modern devcie fabrication
 - scaling laws
 - from photo- to nanolithography and self-assemling
 - technologies for the material deposition and the surface structuring in order to result in certain electrical and other properties
 - · nanotools for the analysis and the modification of surfaces
 - · surface topography on micro- and nanolevel: AFM, SEM/TEM, IOM

Future technologies

- From MEMS to NEMS
- fullerene-based nanosystems
- · biomedical applications of the nanotachnolgy
- micro- and nanofluidics
- nanosafety and risks

Teaching and learning methods

lectures and exercises

Literature

Assessment

Certification requirements

Module does not use certification requirements

Basic principle for exams

As a rule, all standard final exams are conducted in written form. For resit exams, lecturers will communicate the exam format (written/oral) together with the exam schedule.

Standard final exam for a module and written resit exam

Kind of exam Written exam Duration of exam 120 minutes Permissible aids No aids permitted

Special case: Resit exam as oral exam Kind of exam Oral exam Duration of exam 30 minutes Permissible aids No aids permitted